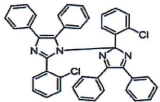
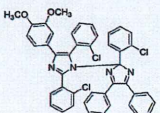
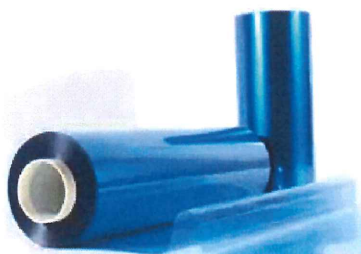


HABI Series

HABI Series

Product	Chemical Structure	Peak Absorption	Feature	Application
TR-HABI-101		261nm	Moderate curing speed and high resolution	Dry film resist
TR-HABI-102		326.5 nm, 349 nm	High solubility and photosensitivity, few developing sludge, absorption wavelength as 400 nm	Dry film resist
TR-NEW-HABI	Closed Information	264 nm, 376 nm	Double band initiator (365nm, 405nm)	Dry film resist

Development and trend of HABI Series



First generation

2000

TR-HABI-101

Break foreign monopolies
Cut down the cost of production
Popular among clients



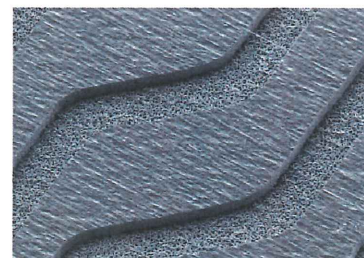
Orbotech LDI device

Second generation

2010

TR-HABI-102

Applied to LDI light source
Improve the property of dry film resist



Micro-view of dual-band product

Third generation

2015

NEW-HABI

355&405 nm dual-band products are developed as the needs of environment protection and popularity of LED light source